Electromagnetic Solvers for Interconnect and Package Modeling - New Developments

#### by

S. M. Rao Department of E & CE, Auburn University, Auburn, AL 36849, USA

- Why do we need Electromagnetic analysis for Interconnects?
- Present day circuit boards involve multi-chip environment connected by transmission lines - Cross talk and Pulse degradation is a major problem in this dense environment.
- Why do we need Electromagnetic analysis for Packaging?
- To minimize the electromagnetic radiation, interference, and adhere to electromagnetic compatibility standards.

#### Methods Of Analysis:

- Analytical Methods Although provide exact solution, almost non-existent for the type of problems encountered in the packaging industry. Mainly, because of complex domains.
- Numerical Methods Provides approximate solutions. However, the methods can handle complex domains, materials and structures. Requires intense computations.

### **General Solution Methodology:**

- Start with Maxwell's Equations.
- Define various material boundaries.
- Apply the electromagnetic boundary conditions.
- Calculate (Estimate) the electric/Magnetic fields within the problem domain.
- Check whether the fields satisfy the boundary conditions.
- If not, refine the solution.
- The process usually involves converting the operator equation into matrix equation and solving it by standard numerical procedures.

We have two approaches.

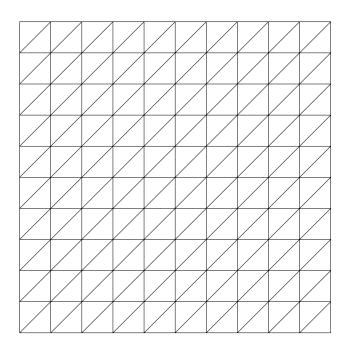
- 1. Differential Equation (DE) Solution Method.
  - The governing equations are sets of differential equations.
  - Solution space is three-dimensional. For open region problems, the space extends to infinity.
  - Generates sparse system matrix.
  - Easy to apply for variety of problems with a general purpose code.
  - Needs more unknowns in the solution for given accuracy.
  - Popular methods are FEM and FDTD.

- 2. Integral Equation (IE) Solution Method.
  - The governing equations are integral equations.

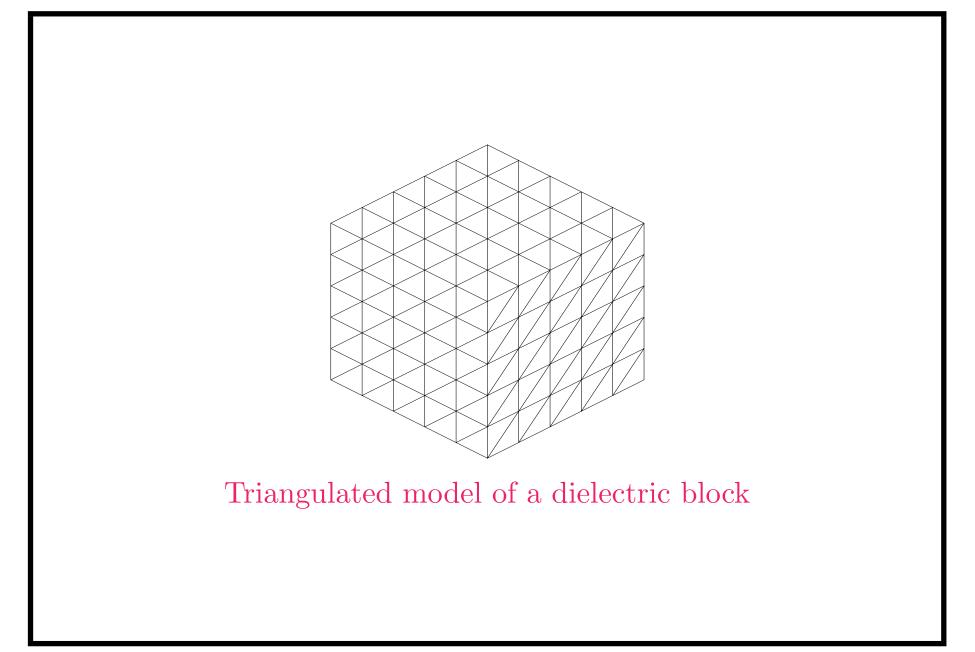
$$\int X(\tau) H(t,\tau) d\tau = Y(t)$$

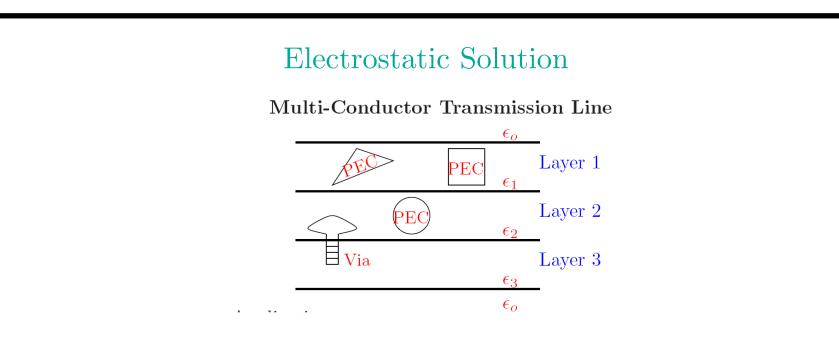
- Solution space, in most cases, is two-dimensional.
- Generates fully populated system matrix.
- Modifications are required for different types of problems even with a general purpose code.
- Generally needs fewer unknowns for given accuracy.
- Popular method is MoM.

**Geometrical Modeling:** Here, we use triangular patch modeling. Approximates any body, both simple and complex, in a most efficient way.



Triangulated model of a conducting plate





- Calculate the charge distribution.
- Generate [R], [G], [L] and [C] matrices.
- Calculate signal velocities.
- Calculate pulse distortion or cross talk

#### Full Wave Solution

The method involves the following steps:

For PEC portion of the structure,

• Develop an integral equation using boundary conditions on the electric field.

For non-conducting (dielectric) portion of the structure,

- Develop a set of coupled integral equations using boundary conditions on both the electric and magnetic fields.
- The unknowns in the equations are the induced currents.

The scattered Electric field  $E^s$  is given by,

$$\boldsymbol{E}^{s}(\boldsymbol{r}) = -j\omega \; \boldsymbol{A}(\boldsymbol{r}) \; - \; \nabla \Phi(\boldsymbol{r}) \tag{1}$$

where

$$\boldsymbol{A}(\boldsymbol{r}) = \mu \int_{S} \frac{\boldsymbol{J}(\boldsymbol{r}') \ e^{-jkR}}{4\pi R} \, dS' , \qquad (2)$$

$$\Phi(\mathbf{r}) = \frac{-1}{j\omega\epsilon} \int_{S} \frac{\nabla \cdot \mathbf{J}(\mathbf{r}') \ e^{-j\kappa\kappa}}{4\pi R} \, dS' , \qquad (3)$$

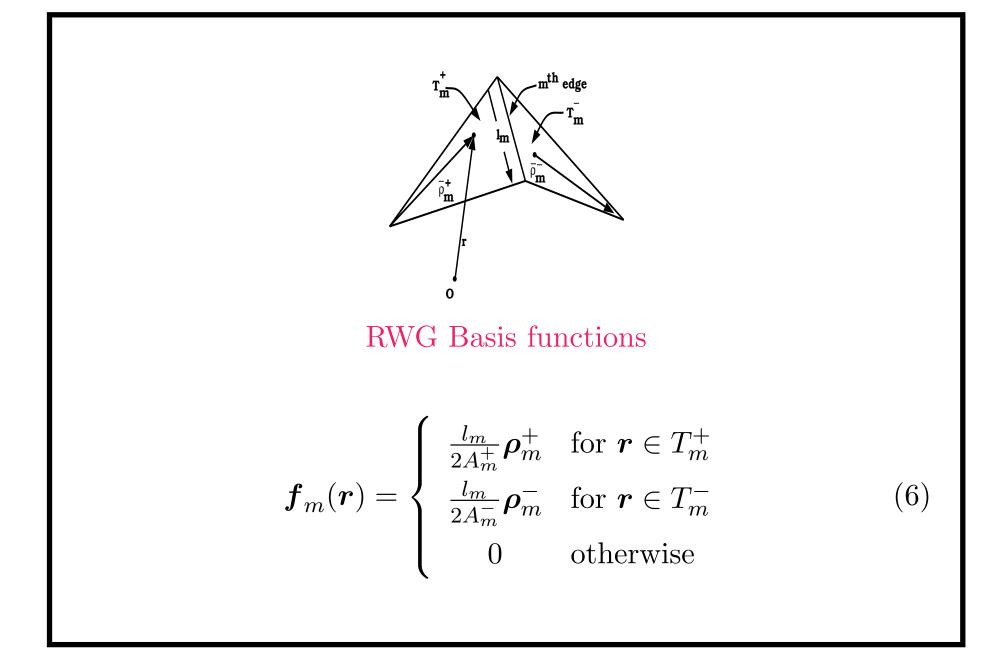
$$R = |\boldsymbol{r} - \boldsymbol{r}'| \tag{4}$$

Applying the Boundary Condition,  $E_{tan} = 0$  on the PEC surface, we have

$$[j\omega \boldsymbol{A}(\boldsymbol{r}) + \nabla \Phi(\boldsymbol{r})]_{tan} = \boldsymbol{E}_{tan}^{i}(\boldsymbol{r})$$
(5)

• Using suitable basis functions to approximate J, that is,

$$\boldsymbol{J} = \sum I_n \boldsymbol{f}_n$$



- $f_n$ 's also used as weighting functions.
- Convert the integral equation into matrix equation.

[Z][I] = [V] and  $[I] = [I_n]$ 

- Solve the matrix equation to obtain  $I_n \implies$  Current induced on the structure is known.
- Calculate required parameters such as electric field, input impedance, inductance, capacitance and so on.

General Purpose Codes Based on RWG Method

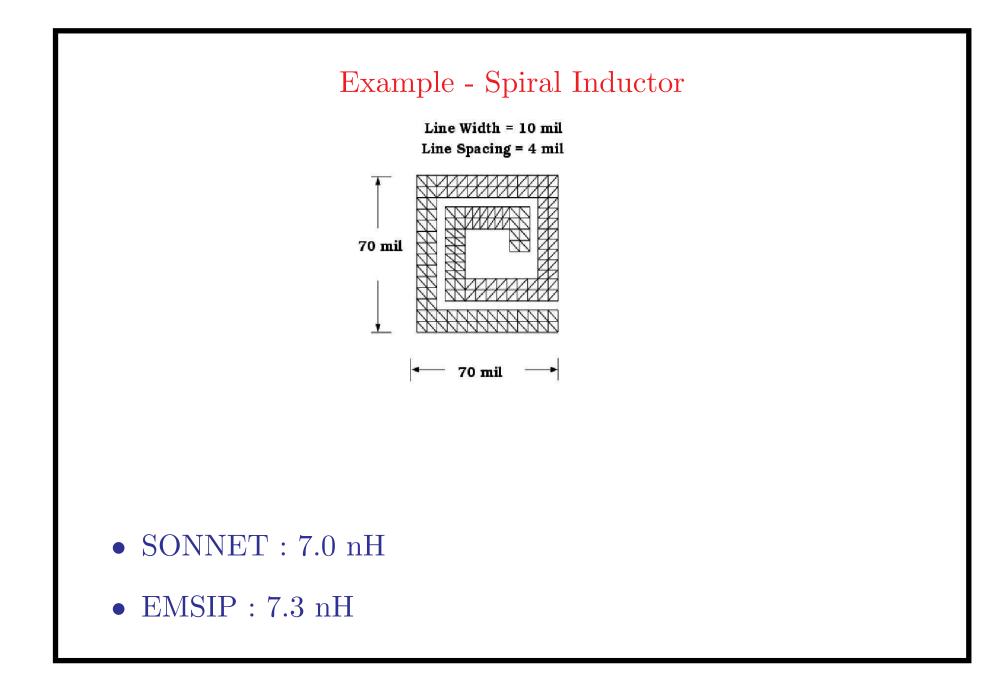
- PATCH Developed by Sandia National Lab.
- FERM Developed by MIT Lincoln Lab.
- IE3D Commercial Software.
- **FEKO** Commercial Software.
- There are host of other codes developed by many companies which all use RWG functions.
- It is also possible to develop a new and more efficient code incorporating latest developments in computer technology and numerical solution procedures.

Design Tool for SIP (System in a Package) or SOP (System on a Package)

- EMSIP Design Tool developed by AU based on RWG functions. An Accurate and Sophisticated Tool for EM Analysis Provides reliable design than commercially available software tools viz. SONNET and ANSOFT.
- SONNET Uses Periodic Greens Function. ANSOFT Uses Finite Element Scheme. Both methods are NOT ideal SIP Modeling Tools.
- EMSIP Tool Based on Method of Moments Most suitable for SIP design. Both time and frequency marching is possible.

Example - Parallel Plate Capacitor

- Top Plate 74 mils  $\times$  46 mils.
- Bottom Plate 84 mils  $\times$  58 mils.
- Plate Separation 1 mil.
- Theoretical Bounds: 0.75 1.08 pf
- SONNET : 1.2 pf
- EMSIP : 0.81 pf



#### Recent Developments

In the past few years, MoM was improved in two ways:

- Improving the matrix-vector products in iterative solution -Fast Multipole Moment (FMM) method. - Very successful -10 million unknown problem has been solved.
- Developing new basis functions, along the lines of wavelets, to generate a sparse matrix - reduces the memory requirements.

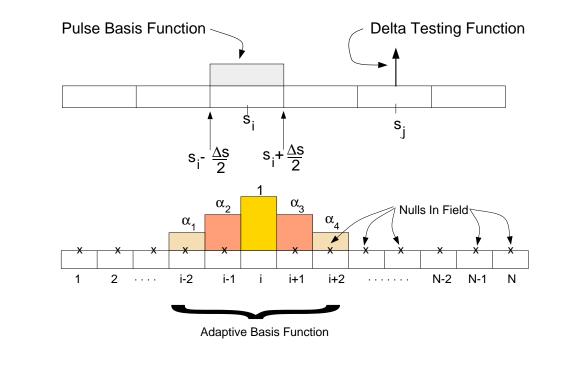
#### Adaptive Basis Functions

- In this work, we develop basis functions, which generate a strong diagonal matrix. In some cases, the off-diagonal elements may be simply discarded.
- None of the major advantages of the MoM are sacrificed.
- Helps in generating for parallel processing.

Construction of Adaptive Basis Functions

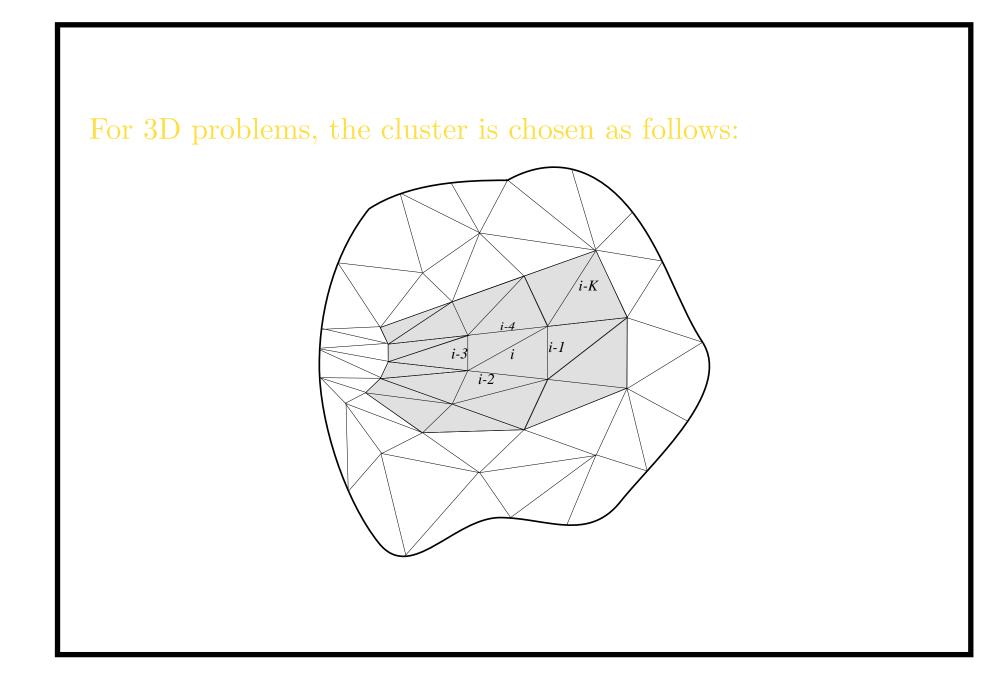
Consider the  $i^{th}$  column of a MoM matrix:

 $Z^{i} = [Z_{1,i}, Z_{2,i}, Z_{3,i}, \dots Z_{N,i},]$ 



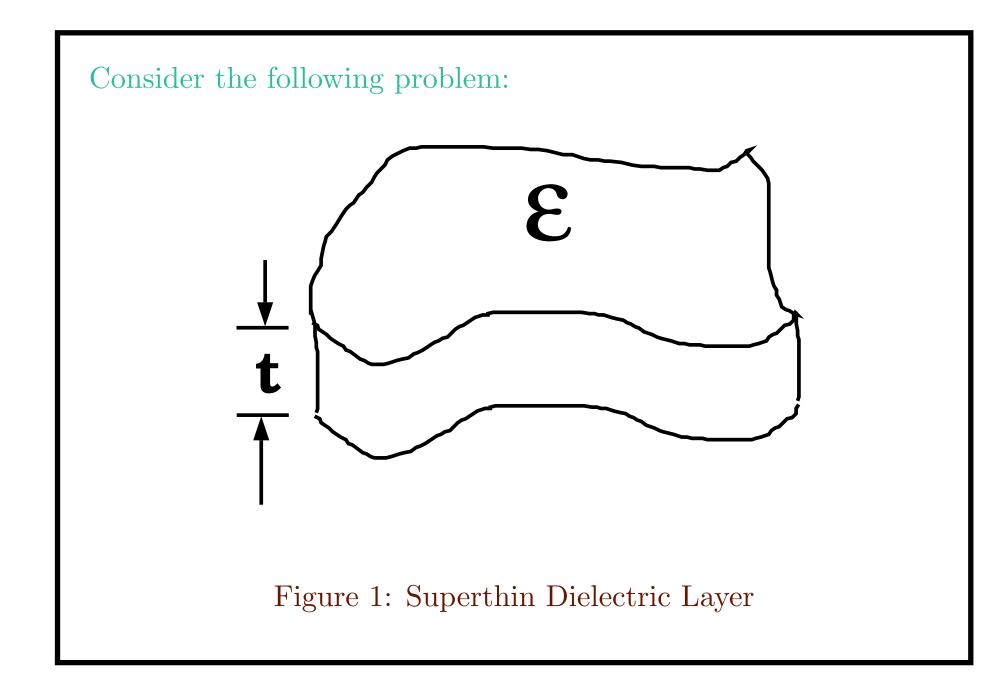
$$[I] = [Z_d]^{-1} ([V] - [Z_{off}][I])$$
  
=  $[I_d] - [Z_d]^{-1} [Z_{off}][I]$ 

(7)



#### Thin Dielectric Solution

- In the conventional MoM, the dielectric material is treated as a slab and triangles are placed over the surface of the slab.
- For the present day chip design and microstrip problems, the dielectrics are extremely thin.
- Cannot be solved using commercial Three Dimensional Codes.
- Requires New analysis methods. A more efficient numerical solution is possible for such cases.

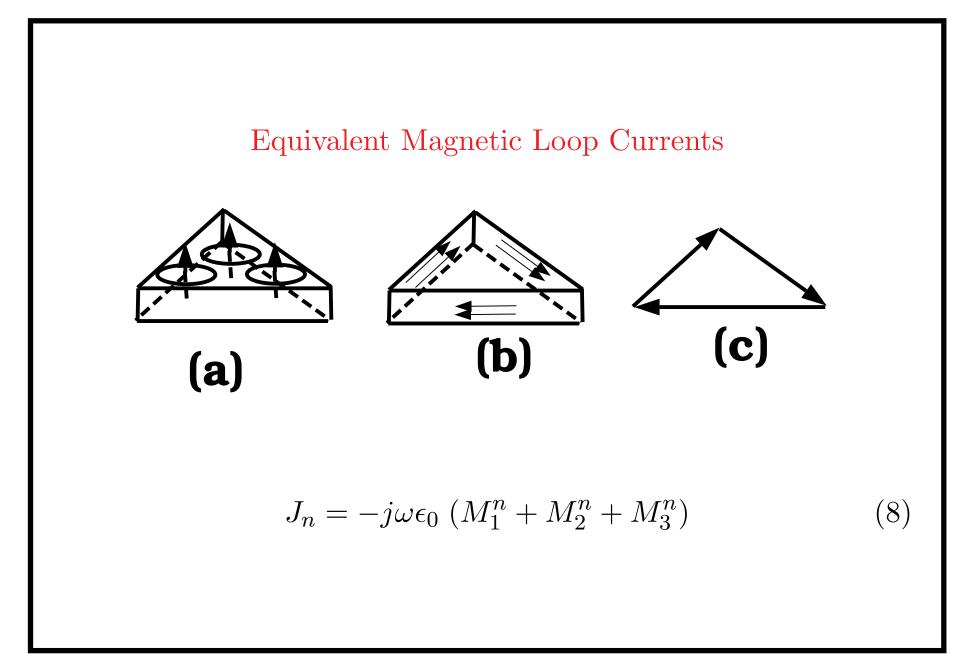


Basic Analysis of Super Thin Dielectric Layer

Using the equivalence principle, the potential theory and free-space Green's function, a pair of integral equations involving the unknown polarization current components  $J_t$  and  $J_n$  to excitation field are derived and solved.

## Numerical Solution Method of Moments Procedure

- 1. Geometrical Modeling The slab is divided into prism elements with triangular base
- 2. The tangential current component  $J_t$  is modeled by standard RWG basis functions
- 3. The normal component  $J_n$  is modeled by two methods: a) using equivalent magnetic loop currents, and b) constant electric currents



#### Constant Normal Electric Current

- For this case,  $J_n$  is assumed to be constant along the thickness.
- To support such currents, we must have two charge layers at top and bottom of the dielectric slab.
- These charge layers must have equal and opposite values.

# Conclusions

In this work,

- Full wave electromagnetic solution methods available to estimate field coupled to various components is presented.
- Only integral equation solution method, MoM, is considered.
- The solution method is versatile and accurate.
- New developments to make the method efficient are also presented.